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Application No.	Applicant(s)	
10/692,888	YANG, SHIH-TSAI	
Examiner	Art Unit	
Shih-Chao Chen	2821	
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<u>t. 27, 2003</u> .		
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	PTO-948) attached	
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SIT OF BIOLOGICAL MATER FOR THE DEPOSIT OF BIOL	RIAL must be submitted. Note the OGICAL MATERIAL.	
6. ☐ Interview Sun Paper No./M 7. ☐ Examiner's Al 8. ☑ Examiner's Si 9. ☐ Other	nmary (PTO-413), ail Date mendment/Comment ratement of Reasons for Allowance	1
	Examiner Shih-Chao Chen Pars on the cover sheet with (OR REMAINS) CLOSED in tor other appropriate community of the same shade of the same	To/692,888 Examiner Shih-Chao Chen 2821 Pars on the cover sheet with the correspondence address-(OR REMAINS) CLOSED in this application. If not included or other appropriate communication will be mailed in due course. THI GHTS. This application is subject to withdrawal from issue at the initial and MPEP 1308. 27, 2003. De Examiner. Inder 35 U.S.C. § 119(a)-(d) or (f). Deben received. Deben received in Application No Cuments have been received in this national stage application from the cuments have been received in this national stage application from the cuments have been received in this national stage application from the cuments have been received in this national stage application from the cuments have been received in this national stage application from the cuments have been received in this national stage application from the cuments have been received in the from the cuments have been received in this national stage application from the cuments have been received in this national stage application from the cuments have been received in this national stage application from the cuments have been received in this national stage application from the cuments have been received in this national stage application from the cuments have been received. Peresponsible to withdrawal from issue at the initial data and the initial stage application from the from this national stage application from the cuments have been received. Peresponsible to withdrawal from issue address. This is application in the comments of this national from the initial data and the initial stage application from the initial stage application

DETAILED ACTION

Allowable Subject Matter

- 1. Claims 1-5 are allowed.
- 2. The following is an examiner's statement of reasons for allowance:

The primary reason for the allowance of claims 1-5 is the inclusion of the limitation of a printed monopole antenna comprising an adjust arm protruding perpendicularly from an elongate length of the third conductive arm towards the first conductive arm. It is this limitation found in each of the claims, as it is claimed in the combination, that has not been found, taught or suggested by the prior art of record which makes these claims allowable over the prior art.

Wong et al. (U.S. Patent No. 6,650,296) teaches the microwave substrate includes a first surface and a second surface. The first horizontal radiating metallic line is printed on the first surface. The second horizontal radiating metallic line is printed on the first surface. Wherein the first horizontal radiating metallic line and the second horizontal radiating metallic line respectively intersect the vertical radiating metallic line at different positions. The feeding point is disposed on the vertical radiating metallic line. However, Wong et al. does not disclose or suggest an adjust arm protruding perpendicularly from an elongate length of the third conductive arm towards the first conductive arm.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably

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accompany the issue fee. Such submissions should be clearly labeled "Comments on

Statement of Reasons for Allowance."

Correspondence

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shih-Chao Chen whose telephone number is (571) 272-

1819. The examiner can normally be reached on Monday-Friday from 7 AM to 4:30

PM, First Fri. off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Don Wong can be reached on (571) 272-1834. The fax phone number for

the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

Shih-lhao Chen Shih-Chao Chen **Primary Examiner**

Art Unit 2821

SXC

December 20, 2004